IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.:

09/833,084

Confirmation No.:

8866

First Named

Ibrahim Abdulhalim et al.

Filing Date:

April 10, 2001

Inventor:

Group Art Unit:

1775

Examiner:

Unknown

Atty. Docket No.:

TNCR.196US0

Title:

PERIODIC PATTERNS AND TECHNIQUE TO CONTINUE CEIL

MISALIGNMENT

Assignee:

KLA-TENCOR CORPORATION

San Francisco, California March 27, 2003

COMMISSIONER FOR PATENTS Washington, D. C. 20231

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Dear Sir:

Pursuant to 37 C.F.R. §§ 1.56, 1.97, and 1.98, Applicants call the documents listed on the enclosed Form PTO-1449 to the Examiner's attention in this patent application.

Copies of the documents listed on the accompanying Form PTO-1449 are enclosed. \boxtimes

Citation of these documents shall not be construed as (1) an admission that the documents are prior art with respect to the invention or inventions claimed in this application, (2) a representation that a search has been made (other than as indicated by any cited document), or (3) an admission that the cited information is, or is considered to be, material to patentability as defined in § 1.56(b).





This information disclosure statement is submitted under 37 C.F.R. § 1.97(b) and consequently no fee should be required.

EXPRESS MAIL LABEL NO.: EV 111851338 US

Respectfully submitted,

Reg. No. 29,545

GROUP 1700 Attorney for Applicant(s)

U.S. Department of Commerce, Patent and Trademark Office						Atty Docket No.			Application No.	
						TNCR.196US0			09/833,084	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT					Applicant(s)			Confirmation No.		
(Use several sheets if necessary)					Ibrahim Abdulhalim, et al.			8866		
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*Examiner Initial		Document Number	Date	Name		Class	Subclass	Filing l Appro		
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	AB	4,332,473	01/05/82	Ono		356	356			
	AD	4,757,207	07/12/88	Chappelow et al.		250	491.1	RECEN	15-	
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	AM									
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Examiner			Date Consid							
*EXAMINEI	R: Initial i	f reference considered mance and not considered	l, whether or i	not citation is in co	onformanc with your	e with MI communi	PEP 609; Drav cation to appl	w line throug	gh	